Developing Low Temperature Contacts for Monolayer TMD Heterostructure Devices

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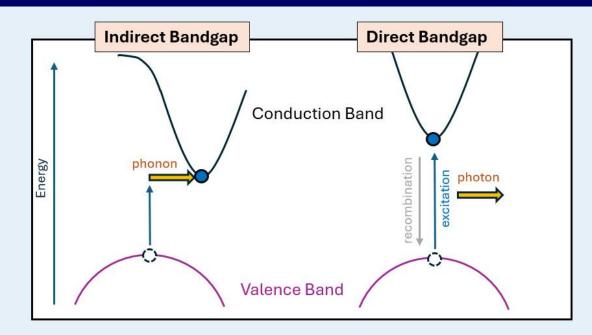
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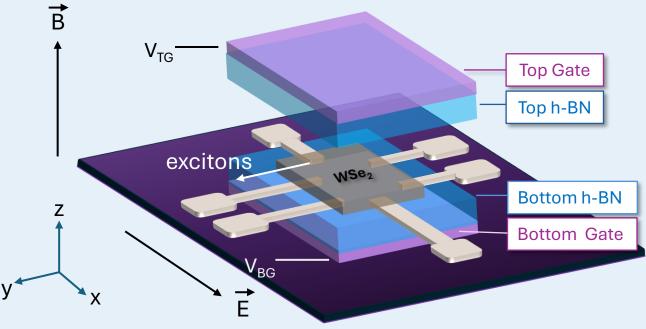
Background

Semiconductor transition metal dichalcogenide (TMD) devices bring efficiency to electronics.

- Silicon-based chip
- Direct band gap in the monolayer limit, by which a photon can be emitted without the aid of a phonon

WSe₂ and device quality through Photoluminescence (PL)

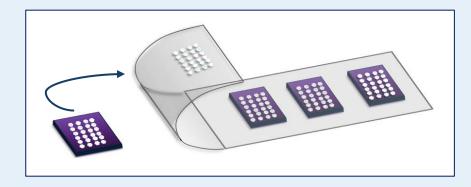




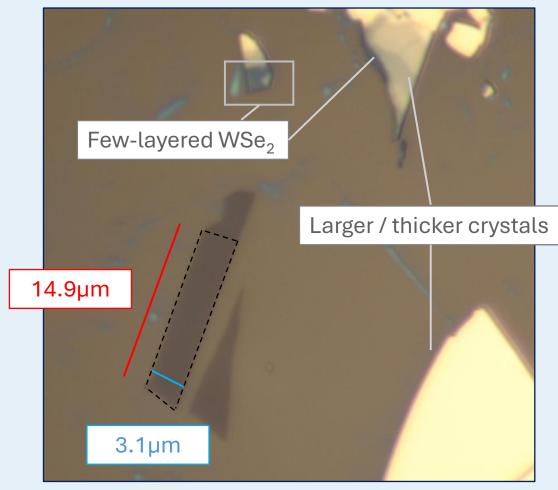
Device Fabrication Method

Mechanical Exfoliation

- Scotch tape cleaves bulk material at where vdW forces < chemical bonds
- An array of replicated, sheared bulk material pressed down onto substrate.
- O₂ plasma organic materials
- Heating of tapes varied adhesion



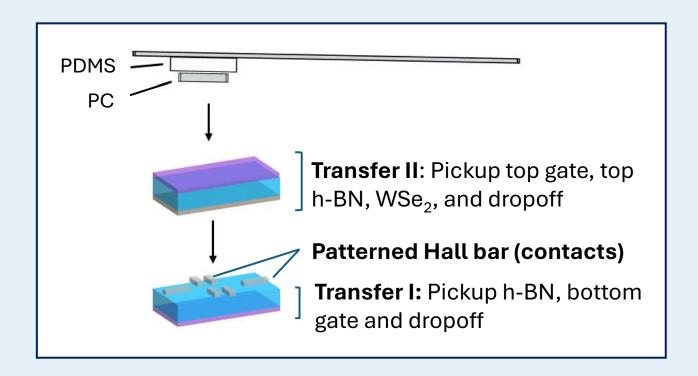
Graphite, h-BN (illustrated), and WSe₂ onto wafer chips



 WSe_2 monolayers (Measurements scaled at 100x on 90nm SiO_2)

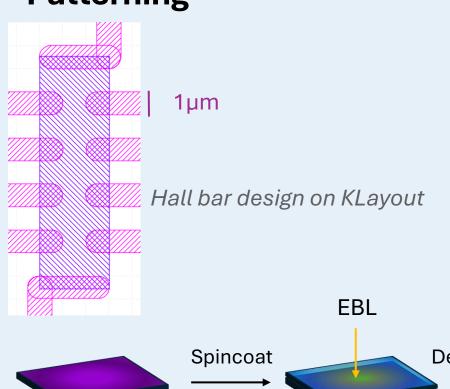
Dry Transfer

- Stacking of samples through picking up and dropping off with PDMS/PC stamp on microscope slide
- Heating / cooling of stamp for adhesiveness





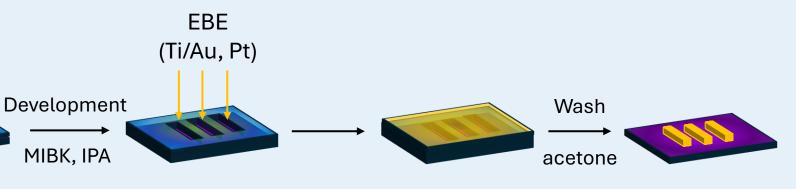
Patterning



950 PMMA A4

+ heat

- · Alignment marks and pre-patterned contacts
- Unique pattern superimposed on alignment marks with transferred on with identical coordinates



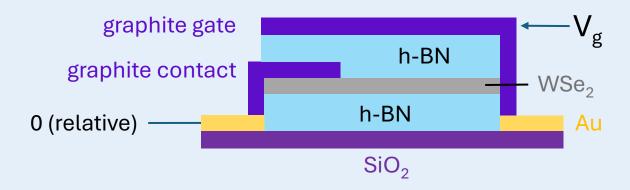
SiO₂ substrate, ideally high R

E-beam lithography (EBL) etches design out of polymer

E-beam
evaporation
(EBE) deposits
material onto
surface

Pattern in material revealed on substrate

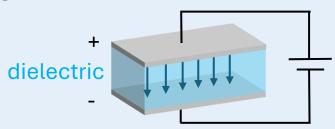
Single-gated device with graphite contact to prepattern

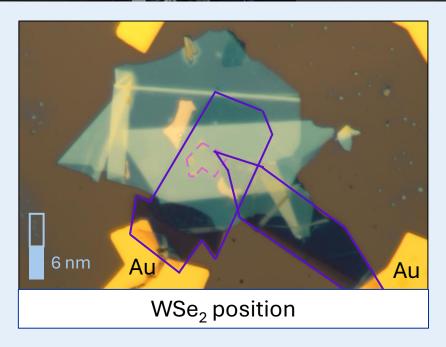


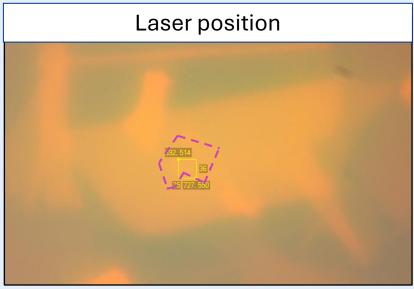
Au vs Pt

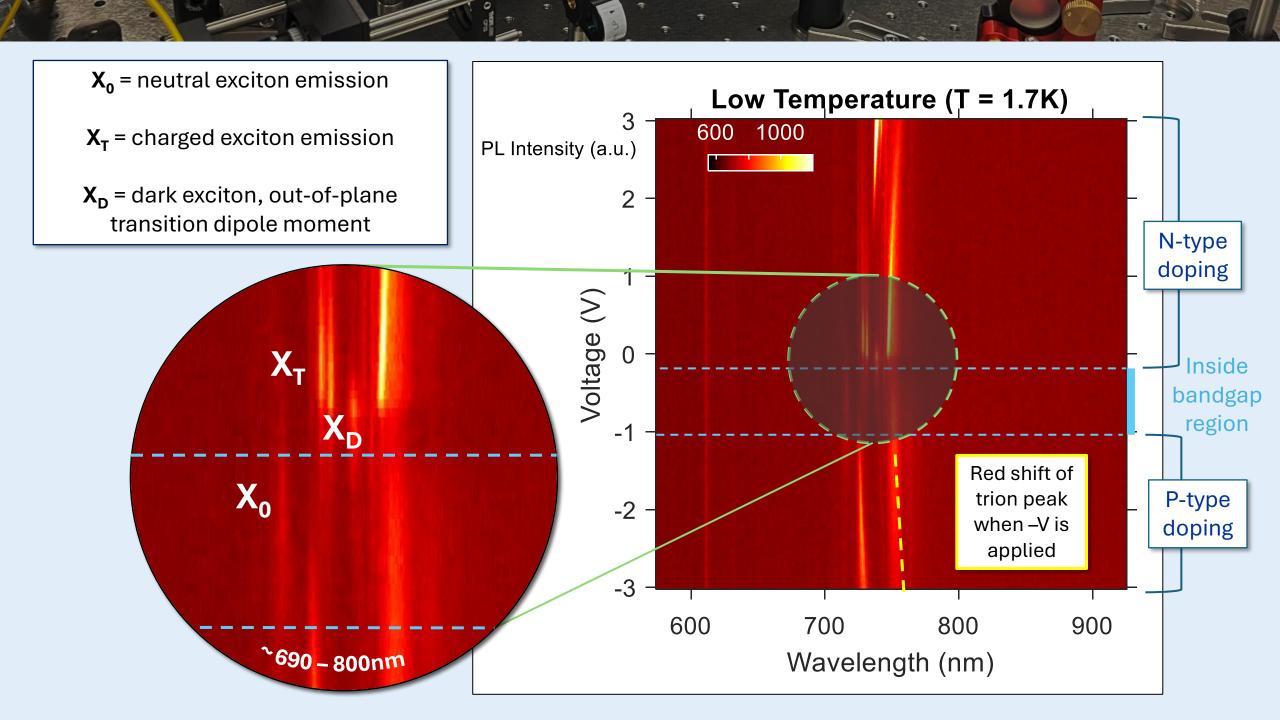
Applied voltage values ——— Wavelength and intensity of light emitted (PL)

Electron doping



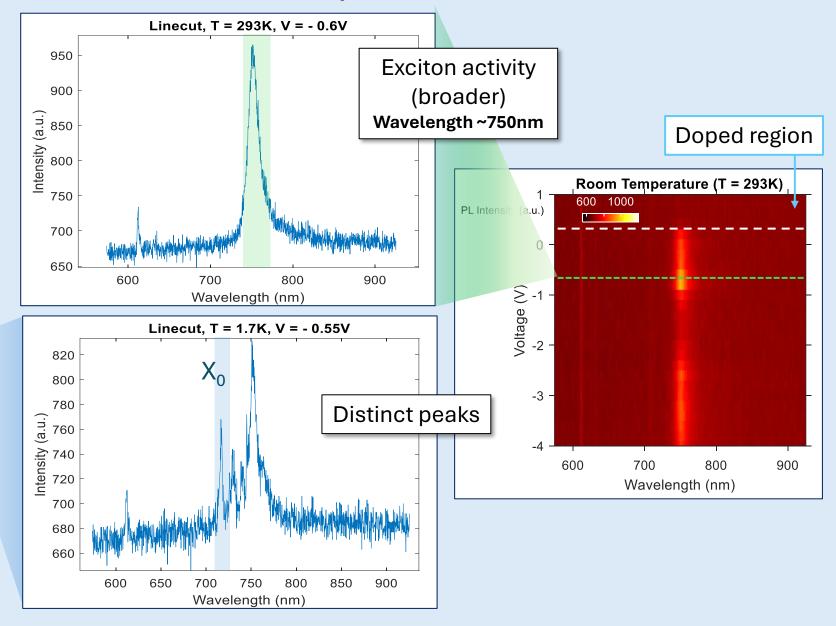




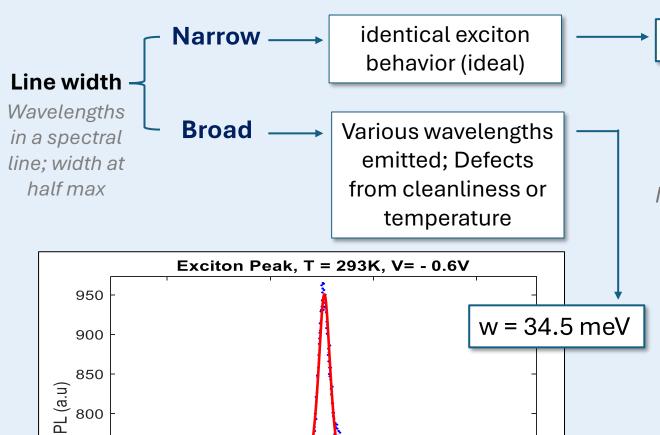


Low Temperature (T = 1.7K) 600 1000 PL Intensity (a.u.) 0.5 -Voltage (V) -1 -750 800 700 Wavelength (nm)

Horizontal linecuts of PL plots



Linecut fitted to Lorentzian function



800

900

700

Wavelength (nm)

750

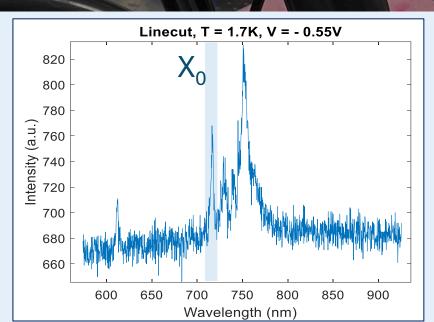
700

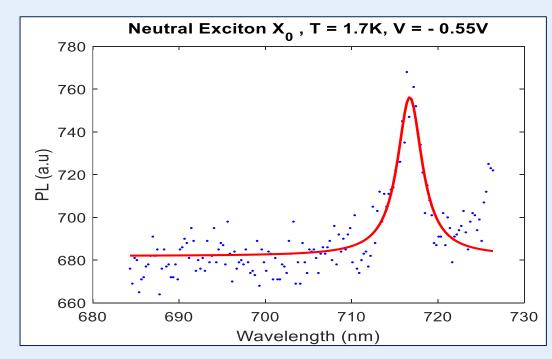
650

600

w = 8.4 meV

w = 2 - 4 meV at 4K (Zhou, et al. Nat. Nanotech.)



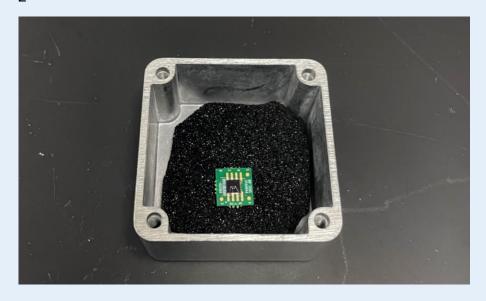


Conclusion

- With current data, we continue with the fabrication of a device with Hall bar patterning
- Current data determine quality of WSe₂
- Guidance for PL

Our reference brings us closer to the ultimate goal of our research of measuring charged transport in developed contacts for WSe₂





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External

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2D materials - hBN

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